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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/647,813	08/25/2003	Paul Albert Kohl	PRMSP0285USB	2354
75	90 07/06/2004	EXAM	EXAMINER	
•	TO, BOISSELLE & S	NGUYEN,	NGUYEN, TUAN H	
Nineteenth Floo 1621 Euclid Ave	·•	ART UNIT	PAPER NUMBER	
Cleveland, OH 44115-2191			2813	
			DATE MAILED: 07/06/2004	4

Please find below and/or attached an Office communication concerning this application or proceeding.

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·		Applica	tion No.	Applicant(s)	85			
Office Action Summary		10/647,	813	KOHL ET AL.				
		Examin	er	Art Unit				
			Nguyen	2813				
Period fo	The MAILING DATE of this commun or Reply	ication appears on t	he cover sheet w	ith the correspond nce addres	s			
THE - External control	MAILING DATE OF THIS COMMUNI resions of time may be available under the provisions SIX (6) MONTHS from the mailing date of this comm e period for reply specified above is less than thirty (3 of period for reply is specified above, the maximum stare to reply within the set or extended period for reply reply received by the Office later than three months a set patent term adjustment. See 37 CFR 1.704(b).	CATION. of 37 CFR 1.136(a). In no an incitation. 0) days, a reply within the statutory period will apply and will, by statute, cause the a	event, however, may a tatutory minimum of thi will expire SIX (6) MOI pplication to become A	reply be timely filed ty (30) days will be considered timely. NTHS from the mailing date of this community BANDONED (35 U.S.C. § 133).	nication.			
Status								
1)[\]	Responsive to communication(s) file	ed on 25 August 200	23					
•	This action is <b>FINAL</b> . 2b)⊠ This action is non-final.							
3)□	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.							
Disposit	ion of Claims							
5)⊠ 6)⊠ 7)□	Claim(s) <u>28-30,39,52 and 71-80</u> is/a 4a) Of the above claim(s) is/a Claim(s) <u>72-80</u> is/are allowed. Claim(s) <u>28-30,39,52 and 71</u> is/are objected to. Claim(s) is/are object to restrict	re withdrawn from o	consideration.					
Applicat	ion Papers							
10)⊠	The specification is objected to by the The drawing(s) filed on 25 August 20 Applicant may not request that any objected to specific properties of the oath or declaration is objected to	003 is/are: a)⊠ acc ction to the drawing(s the correction is requ	) be held in abeya uired if the drawing	nce. See 37 CFR 1.85(a). g(s) is objected to. See 37 CFR 1.				
Priority	under 35 U.S.C. § 119							
a)	Acknowledgment is made of a claim  All b) Some * c) None of:  1. Certified copies of the priority  2. Certified copies of the priority  3. Copies of the certified copies application from the Internation  See the attached detailed Office action	documents have be documents have be of the priority docur anal Bureau (PCT R	een received. een received in A ments have beer cule 17.2(a)).	Application No I received in this National Stag	je			
Attachmer	• •		🗀					
	ce of References Cited (PTO-892) ce of Draftsperson's Patent Drawing Review (F	PTO-948)		Summary (PTO-413) s)/Mail Date				
3) 🛛 Infor	rmation Disclosure Statement(s) (PTO-1449 or er No(s)/Mail Date <u>8/25/03</u> .			Informal Patent Application (PTO-152	)			

## **DETAILED ACTION**

## Claim Rejections - 35 USC § 112

The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

Claim 29 is confusing and indefinite since it is unclear as to what happens to the second material used in the process step (II) but not included in the final product as recited in the first 6 lines; in the process step (V), how could the gas passes through the overcoat layer without passing through the underlying second material?

Claim 30 is confusing and indefinite, since it is unclear as to what would support the overcoat layer when the air gap has a height that exceeds the height of an adjacent conductive line?

Claim 39 recites the limitation "the norbornene polymer" in line 2. There is insufficient antecedent basis for this limitation in the claim.

Claim 71 recites the limitation "the <u>first</u> overcoat layer" in the last paragraph, line

2. There is insufficient antecedent basis for this limitation in the claim; last two lines, it
is unclear as to how could an "overcoat layer of material" recited in the previous step
"yielding overcoated conductive structures"? how could "material" become "conductive"?

## Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

<sup>(</sup>b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

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Claims 28, 29, 52, 39 are rejected under 35 U.S.C. 102(b) as being anticipated by Kaanta et al. (cited by applicant).

Kaanta et al., figs. 1a-1h discloses the claimed semiconductor device having one or more air gaps 25 comprising a substrate 10, at least one conductive line 12, at least one air gap 25 and an overcoat layer 16 (see the final product in fig. 1h and related text on col. 2-3).

With respect to claim 52, Kaanta et al., figs. 1a-1h shows embodiment using air gap between lines on the same level (intralayer), but on col. 1, lines 5-10, lines 28-31, lines 45-51 disclose the air gap formed between lines on superposed layer (interlayer) in VLSI or ULSI circuits.

The claimed process steps have not given any patentable weight since a "product-by-process" claim is directed to a product per se, no matter how actually made, In re Hirao, 190 USPQ 15 at 17 (footnote 3). See also In re Brown, 173 USPQ 685; In re Luck, 177 USPQ 523; In re Fessmann, 180 USPQ 324; In re Avery, 186 USPQ 161; In re Marosi et al., 218 USPQ 289, all of which make it clear that it is the patentability of the final product per se which must be determined in a "product-by-process" claim, and not the patentability of the process, and that old or obvious product produced by a new method is not patentable as a product, whether claimed in "product-by-process claim or not. Note that applicant has the burden of proof in such cases, as the above caselaw makes clear.

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The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Babich et al. discloses multiplayer interconnect structure containing air gaps.

## Allowable Subject Matter

Claim 71 would be allowable if rewritten or amended to overcome the rejection(s) under 35 U.S.C. 112, second paragraph, set forth in this Office action.

Claims 72-80 are allowed.

The following is a statement of reasons for the indication of allowable subject matter: None of the references of record teaches or suggests the claimed semiconductor structure including the overcoat layer material extending into one or more spaces between the sacrificial material and the conductive material.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Tuan H. Nguyen whose telephone number is 571-272-1694. The examiner can normally be reached on 9AM-5:30PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Carl Whitehead Jr. can be reached on 571-272-1702. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

man A - Nguyen
Tuan H. Nguyen
Primary Examiner
Art Unit 2813